



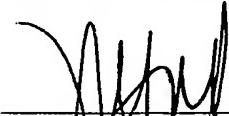
1752

PATENT
30205/37777

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Jae Chang Jung et al.)
Serial No.: 10/054,095)
Filed: January 22, 2002)
For: Chemical Amplification)
Photoresist Monomers, Polymers)
Therefrom and Photoresist)
Compositions Containing the Same)
Group Art Unit: 1752)
Examiner: Rosemary E. Ashton)

I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on November 21, 2003, in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450



Michael R. Hull
Reg. No. 35,902
Attorney for Applicants

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

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TC 1700

Dear Sir:

In response to the office action mailed on August 21, 2003, please amend the above-identified patent application as follows: